L Number	Hits	Search Text	DB	Time stamp
1	89	(photosensitive near2 (paste film) photoresist photocurable)	USPAT;	2003/12/23 16:49
		and (polymer copolymer) and ((acrylic methacrylic	US-PGPUB	
		vinylacetic) adj acid and (styrene methylstyrene		
		metha\$2acrylate)) and glycidyl and ethylenically adj		
		(unsaturated double) adj bond		
2	27	((photosensitive near2 (paste film) photoresist photocurable)	USPAT;	2003/12/23 16:4
		and (polymer copolymer) and ((acrylic methacrylic	US-PGPUB	
		vinylacetic) adj acid and (styrene methylstyrene		
		metha\$2acrylate)) and glycidyl and ethylenically adj		
		(unsaturated double) adj bond) and ethylenically adj		•
		unsaturated adj bond same no		
3	42	((photosensitive near2 (paste film) photoresist photocurable)	USPAT;	2003/12/23 16:42
		and (polymer copolymer) and ((acrylic methacrylic	US-PGPUB	2000/12/20 10.42
		vinylacetic) adj acid and (styrene methylstyrene	00-1 01 05	
		metha\$2acrylate)) and glycidyl and ethylenically adj	ļ	
		(unsaturated double) adj bond) and acid adj anhydride		
4	30	((photosensitive near2 (paste film) photoresist photocurable)	LIODAT	0000/10/00 10 10
4	30	ond (notwood analyment) and ((comiling the first photocurable)	USPAT;	2003/12/23 16:43
		and (polymer copolymer) and ((acrylic methacrylic	US-PGPUB	
İ		vinylacetic) adj acid and (styrene methylstyrene		
		metha\$2acrylate)) and glycidyl and ethylenically adj		
		(unsaturated double) adj bond) and acid adj (number value)		
		and (molecular adj weight dalton)		
5	42	(((photosensitive near2 (paste film) photoresist photocurable)	USPAT;	2003/12/23 16:44
		and (polymer copolymer) and ((acrylic methacrylic	US-PGPUB	
		vinylacetic) adj acid and (styrene methylstyrene		
-		metha\$2acrylate)) and glycidyl and ethylenically adj		
		(unsaturated double) adj bond) and acid adj anhydride) and		
		(stabili\$2er acid phosphor\$4 sulf\$6)		
6	3	((photosensitive near2 (paste film) photoresist photocurable)	USPAT:	2003/12/23 16:47
		and (polymer copolymer) and ((acrylic methacrylic	US-PGPUB	2000/12/20 10.47
		vinylacetic) adj acid and (styrene methylstyrene	0010100	
		metha\$2acrylate)) and glycidyl and ethylenically adj		
		(unsaturated double) adj bond) and (low adj melting silicate		
		zinc bismuth lithium) near2 glass near2 (powder particle) and		
		(metal oxide) near2 (powder particle granule) and (particle		
		grain) near? (cize diameter missen) and (viduosint) and (particle		
		grain) near2 (size diameter micron) and (wt weight) near2		
7	10	(percent '%' part)	1	
'	10	((photosensitive near2 (paste film) photoresist photocurable)	USPAT;	2003/12/23 16:48
		and (polymer copolymer) and ((acrylic methacrylic	US-PGPUB	
		vinylacetic) adj acid and (styrene methylstyrene		
	i	metha\$2acrylate)) and glycidyl and ethylenically adj		1
	J	(unsaturated double) adj bond) and ((low adj melting silicate		
		zinc bismuth lithium) near2 glass near2 (powder particle)		
		(metal oxide) near2 (powder particle granule)) and (particle		
	I	grain) near2 (size diameter micron) and (wt weight) near2		
	Į	(percent '%' part)		
9	18	((photosensitive near2 paste photoresist photocurable) and	EPO: JPO:	2003/12/23 16:50
f		(polymer copolymer) and ((acrylic methacrylic vinylacetic)	DERWENT	2000, 12/20 10:00
	i	adj acid and (styrene methylstyrene metha\$2acrylate))) and	DEIXVENT	
		((glass metal oxide) near2 (particle powder) acid adj (value		
		number) (molecular adj weight dalton) (particle grain) near2		
	İ	(cize diameter) (ut weight) near2 (next nemer 1941)		
10	7	(size diameter) (wt weight) near2 (part percent '%'))		
10	7	((photosensitive near2 paste photoresist photocurable) and	EPO; JPO;	2003/12/23 16:50
1		(polymer copolymer) and ((acrylic methacrylic vinylacetic)	DERWENT	
Ì		adj acid and (styrene methylstyrene metha\$2acrylate))) and		
		glycidyl		
11	4	((photosensitive near2 paste photoresist photocurable) and	EPO; JPO;	2003/12/23 16:50
	1	(polymer copolymer) and ((acrylic methacrylic vinylacetic)	DERWENT	
	- 1	adj acid and (styrene methylstyrene metha\$2acrylate))) and		
	İ	acid adj anhydride		
12	41	ichikawa near2 kyo.in. takagi near2 kouichi.in. nobuyuki	USPAT;	2003/12/23 16:51
		near2 suzuki.in	US-PGPUB;	2000/12/23 10:01
1				
			EPO; JPO; DERWENT	

13	30	10087769.did. 09316149.did 09218509.did. 11031416.did.	USPAT;	2003/12/23 16:52
		10273338.did 07248619.did. 1048815.did. 1087769.did.	US-PGPUB;	
		9316149.did 9218509.did 1131416.did. 10273338.did.	EPO; JPO;	
		7248619.did "5973034"	DERWENT	<u> </u>